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# **Generation of 60 GHz Dual-Mode Optical BPSK Signal Pair for Crosstalk-Free QPSK Photodetection by Optical Modulation Scheme with Double RF Inputs and Suppressed Carrier Feature**

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SUMMARY A novel optical modulation scheme is proposed for synthesizing a pair of dual-mode optical BPSK signals with an orthogonal phase relationship via a LiNbO<sub>3</sub> Mach-Zehnder modulator (MZM) with dual RF signal inputs and a carrier suppression feature, which enables the generation of a crosstalk-free QPSK signal at the photodetection stage. With this method, one can compensate the drawback, that is bandwidth broadening, in our previously proposed method where a dual-mode optical QPSK signal is generated on the basis of narrow-angle modulated QPSK signal injection into a double-sideband suppressed carrier MZM device. We have carried out experiments for 60 GHz performance demonstration of this QPSK signal generation mechanism, and the results indicate the effectiveness of the present scheme.

key words: RoF technique, optical millimeter-wave signal generation, dual-mode optical signal, QPSK modulation format, LN modulator

# 1. Introduction

Fiber-optic transmission of radio-frequency or millimeter-wave (mm-wave) frequency signals is one of the technical issues studied most actively in the field of microwave photonics [1], [2]. In a conventional sense, the transparency feature is highly demanded at both ends of a fiber-optic link where the electrical-to-optical and optical-to-electrical conversion processes take place with little bandwidth limitation or nonlinear distortion being preferred. On the other hand, one can note that there exists another recent trend, where attractive functionality is brought about at the stage of electrical-to-optical conversion by the utilization of advanced optical modulation devices and their novel driving techniques. For example, it is possible to multiply an electrical carrier frequency by making use of nonlinear characteristics of a LiNbO3 (LN) Mach-Zehnder modulator (MZM) [3], [4]. A driving method called

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double-sideband modulation with suppressed carrier (DSB-SC) [3] is the most representative and probably smartest methocl of providing such a useful functionality as frequency-doubling. Its dual optical mode property is, furthermore, advantageous for the efficient suppression of the dispersion-incluced power penalty problems.

One should note, however, that the nonlinearity eliminates some important modulator operations relying on device linearity. For instance, an RF signal in a phase-shift-keying (PSK) modulation format cannot be applied directly to the conventional DSB-SC scheme. This is rather troublesome since the PSK modulation format is widely applied in many wireless communications systems. On the other hand, it is known that the signal-preprocessing scheme at the electrical stage is effective in overcoming such nonlinearity-oriented obstacles. Indeed, injection of a narrow-angle (NA-) PSK signal into an MZM device with the DSB-SC configuration turns out to be the same as photodetection output in a binary-PSK (BPSK) modulation format, as demonstrated in our previous work.

In this paper, we report on our attempt to extend the performance of this advantageous method in order to deal with more sophisticated signal generation; we propose a method that enables one to generate a pair of dual-mode optical BPSK signals via an LN optical modulator with dual RF inputs and a carrier suppression feature. In conjunction with the appropriate bias setting, i.e., quadrature optical bias setting for two arms of the MZM device, this scheme leads to the generation of a quadrature-PSK (QPSK) signal at the stage of photodetection without causing fatal crosstalk. In comparison with the previously proposed method of QPSK signal generation where an NA-QPSK electrical signal is injected into a DSB-SC MZM device, one can expect less spectral broadening since the transient trajectories in the present scheme are less complicated and consequently lead to narrower bandwidths. This feature leads preferably to robust operations in bandwidth-limited systems. Thus, it is expected that our proposed QPSK modulation

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scheme, based only on a single optoelectronic device, provides the frequency-doubling functionality as well as the dispersion-tolerant-characteristics, which may lead to cost-effective implementation of advanced optical mm-wave transmitters at a central office in future fiber-optic picocell configurations.

#### 2. Orthogonal Dual-Mode BPSK Signal Pair

Let an MZM device with a pair of RF inputs and carrier suppression functionality be considered here to explain the operation principle of the present scheme (Fig.1). The device can be either an optical single-sideband (SSB) modulator [5]-[7] or dual-electrode MZM device. The former consists of two MZM devices in parallel, and the latter is regarded as a parallel composite of two independent phase modulators. Such a device allows one to generate two dual-mode optical signals independently from a single optical carrier by injecting two driving electrical signals separately. Here, the elimination of the optical carrier component is advantageous for higher efficiencies in optical amplification and optical-to-electrical conversion processes as well as for suppression of the dispersion-induced power penalty in the case of phase modulators. This is possible by means of the DSB-SC operation of each integrated modulator in the former device, and an optical band rejection filter is additionally needed for the latter device. Here, a fiber Bragg grating (FBG) is probably suitable for the mm-wave application.

Let an optical carrier of frequency  $\Omega$  be launched into two optical paths in the device and also phasemodulated individually through injection of an RF signal with frequency  $\omega_i$  and NA-BPSK data of  $\phi_i$ . Here, the subscript *i* identifies optical modulation in each optical path. Hereafter, we concentrate on the optical SSBM as a representative case. The DSB-SC modulation scheme for the SSBM device gives rise to the generation of upper and lower sidebands, as well as to the suppression of the carrier component, as mentioned above. The lower and upper sideband optical fields are expressed as  $E_i \exp j\{(\Omega - \omega_i)t - \phi_i\}$  and  $E_i \exp j\{(\Omega + \omega_i)t + \phi_i\}$ . Phasers of the dual-mode



Fig. 1 Schematic of a LiNbO<sub>3</sub> modulator being considered; it should have double RF input ports and electrodes as well as the carrier suppression feature. One can use either the optical SSBM or dual-electrode MZM device. The former consists of two MZM devices in parallel and the latter contains two independent phase modulators (PM). The latter needs an external optical band elimination filter for carrier suppression.

optical signals thu S generated are schematically drawn in Figs. 2(a) and (b).

If one sets the DC bias relationship to be quadrature, an optical phase difference of  $\pi/2$  is introduced between these two optical signals. Here, the resultant electrical field at the optical modulator output is expressed as

$$E_{out} = E_1 \exp j\{(\Omega - \omega_1)t - \phi_1\} + E_1 \exp j\{(\Omega + \omega_1)t + \phi_1\} + E_2 \exp j\{(\Omega - \omega_2)t - \phi_2 + \pi/2\} + E_2 \exp j\{(\Omega + \omega_2)t + \phi_2 + \pi/2\}.$$
(1)

The RF current *ip* generated at the photodetection stage is consequently given by

$$i_p \propto 2E_1^2 \cos(2\omega_1 t + 2\phi_1) + 2E_2^2 \cos(2\omega_2 t + 2\phi_2) + 2E_1E_2 \cos\{(\omega_1 + \omega_2)t + \phi_1 + \phi_2 + \pi/2\} + 2E_1E_2 \cos\{(\omega_1 + \omega_2)t + \phi_1 + \phi_2 - \pi/2\} = 2E_1^2 \cos(2\omega_1 t + 2\phi_1) + 2E_2^2 \cos(2\omega_2 t + 2\phi_2).$$
(2)

Figures 2(c)-(e) indicate the I/Q diagrams of these signals at RF frequencies of  $\omega_1$  (c),  $2\omega_2$  (d) and  $\omega_1 + \omega_2$ (e), respectively, which correspond to the respective terms in the above equation. The RF phases  $2\phi_1$ and  $\phi_2$  indicated in Figs.2(c) and (d) are given by the phase differences between two optical sidebands in Figs.2(a) and (b), respectively. RF phases of the two remaining terms are also indicated in Fig.2(e); one is the optical phase difference between the upper sideband in (b) and the lower sideband in (a), and the other is vice versa. Note that this relationship makes



Fig.2 (a) and (b) Relative phase relationships of optical modes generated by an MZM device, which correspond to phasemodulated light with a  $\pi/2$  phase difference. I/Q diagrams of RF signals generated by optical overlap of the optical modes and their photodetection, RF frequencies  $2\omega_1$  (c),  $2\omega_2$  (d) and  $\omega_1 + \omega_2$  (e), USB: upper sideband, LSB: lower sideband, C: carrier.

the  $\omega_1 + \omega_2$  terms vanish, which provides the orthogonal relationship between the two photodetected outputs and prevents crosstalk problems.

Here, we assume a situation where this operation scheme is applied to the generation of a photodetectecl signal in the QPSK modulation format. We provide the following condition so as to inject a set of the input electrical signals shown in Figs.3(a) and (b) into the MZM device:  $E_1 = E_2$ ,  $\omega_1 = \omega_2$ ,  $\phi_1 = m\pi/4$ and  $\phi_2 = n\pi/4 + \pi/4$ . Here, m and n denote indices of binary phase shifts (±1) for the injected NA-BPSK signals. The phase difference of  $\pi/4$  between the injected NA-BPSK signals gives rise to the orthogonal phase relationship, the second orthogonality, between the photodetected BPSK signals. Thus, the quadrature BPSK signal, that is, a QPSK signal, is generated at the frequency of  $2\omega_1$ ; consequently,

$$i_p \propto 2E_1^2 \{\cos(2\omega_1 t + m\pi/2) + \sin(2\omega_1 t + n\pi/2)\}.$$
(3)

Here, one should note that the transient trajectories of the present QPSK signal are more similar to the ideal ones than those in the case of NA-QPSK signal injection, which suggests some superiority of this method over the previous one in terms of the bandwidth.



Fig.3 I/Q diagrams are shown for one original NA-BPSK signal (a) and the other NA-BPSK signal, whose phase difference is  $\pi/4$  (b). Photodetected BPSK signals corresponding to (a) and (b) are shown in (c) and (d), respectively. The measured 30 GHz NA-BPSK signal injected into one of the optical SSB modulator inputs (e) and the 60 GHz QPSK signal at the PD output with electrical amplification (f).

In the final part of this subsection, we describe subcarrier multiplexing (SCM) where the parameters are set as follows:  $\omega_1 \neq \omega_2$ ,  $\phi_1 = m\pi/4$  and  $\phi_2 = n\pi/4$ . Here, the photocurrent is given by

$$i_p \propto 2E_1^2 \cos(2\omega_1 t + m\pi/2) + 2E_2^2 \cos(2\omega_2 t + n\pi/2).$$
(4)

It should be noted here that, in this SCM method, one can avoid such nonlinearity-oriented problems as (a) intermodulation distortion and (b) generation of unnecessary frequency components at  $\omega_1 + \omega_2$ , which are, in general, caused by electrical addition of two NA-BPSK signals prior to their injection into a DSB-SC MZM device. Such optical addition prevents the former problem because two independent RF signals are fed into two integrated modulators separately. The latter is overcome by setting the orthogonal phase relationship between the two optical paths, as long as no additional phase shift is added during fiber-optic transmission.

## 3. Experiments

In order to confirm the operation principle of the present scheme, we performed 60 GHz experiments in which an electrical (photodetected) QPSK signal was generated by means of the above-mentioned method. The configurations employed for the experiments are shown in Figs.4; we applied the scheme to two kinds of LN modulators: an x-cut optical SSBM device [8] (Fig.4(a)) and a dual-electrode MZM device combined with an FBG band elimination filter (Fig.4(b)).

In Fig.5, the experimental setup used for the demonstration is shown. To generate a set of BPSK



Fig.4 Configurations for QPSK signal generation. While an optical SSBM device is used in (a), a dual-electrode Mach-Zehnder interferometer modulator is combined with a fiber Bragg grating in (b). The input and output signals (1), (2) and (3) correspond to I/Q diagrams (a), (b), and an overlap of (c) and (d) in Figs. 3, respectively.



Fig.5 Experimental setup for QPSK signal generation through the generation of orthogonal dual-mode optical BPSK signals with an LN optical modulator. EOM in the lower left indicates an electrooptic modulation scheme with dual RF inputs and carrier suppression feature. One candidate device for the scheme is an optical SSBM device and another is a dualelectrode MZM device. In the latter case, a fiber Bragg grating is used for elimination of the optical carrier component.

signals to be injected into the optical modulator, we prepared an NA-BPSK modulated electrical signal, divided it into two, and delayed one of these two by a quarter-wave. This was merely for the sake of simplicity, and two independent NA-BPSK signals should be injected in an actual case. The original NA-BPSK signal was generated with an attenuator and a phase shifter, as shown in the upper left of Fig.5, which was measured as the I/Q trace shown in Fig.3(e). Light emitted from a distributed feedback laser diode was led into the LN modulator, modulated by the abovementioned electrical signals, and subsequently amplified through an Er-doped fiber amplifier (EDFA). An optical band-pass filter was set at the output of the EDFA in order to suppress its amplified spontaneous emission noise.

Figure 6(a) shows optical spectra measured for optical mm-wave signals generated with the optical SSBM device. One should note that there exists a difference in the spectral power values between the two peaks. This originates from the difference in the phase relationship between individual BPSK components in each sideband spectrum and can be explained quantitatively as follows. If one takes into consideration the phase differences of  $\pi/2$  in the optical domain and  $\pi/4$  in the RF domain, the optical modal power difference should be given by

$$20 \times \log \left\{ \cos \left( \frac{\pi/2 + \pi/4}{2} \right) / \cos \left( \frac{\pi/2 - \pi/4}{2} \right) \right\}$$
  
= 7.6 [dB]

for the case of single tone signal injection. Since the 5.9dB difference corresponds to a 7.2 dB power differ-



Fig.6 Dual-mode optical signal generated by the present method with an optical SSBM device (a). RF spectrum of 60 GHz QPSK signal measured at the electrical amplifier output after photodetection (b).

ence in the case of single tone signal injection, which has been experimentally confirmed, a fairly good agreement is thus obtained. Consequently, a QPSK signal of the 60 GHz band was successfully generated at the photodetection stage; Fig.3(f) shows a clear I/Q diagram of the QPSK signal thus obtained. This experimental result confirms the our proposed operation principle.

Figure 6(b) shows the RF spectrurn measured around 60 GHz. The RF carrier component was apparently suppressed. On the other hand, there exists a periodic distortion in the spectrum, which is probably due to the residual interference between the two BPSK signals. This is because the origin of the two signals is the same in this particular experiment and the modulator therefore acts as a Mach-Zehnder filter. Indeed, the spectral period is approximately 150 MHz, which coincides with the inverse of the time difference between two input signals. If the two signals are independent of each other, which is more realistic, the spectral distortion may disappear.

Furthermore, we performed a similar experiment with a dual-electrode MZM device with an FBG band elimination optical filter. The inset of Fig.7 shows the measured I/Q diagram, which suggests that the scheme works well also with the second device. The result of bit-error-rate (BER) measurement (156Mbps) performed for a demodulated mm-wave signal is indicated in Fig.7. While a separate measurement indicates a clear eye opening for the signal, BER of  $< 10^{-9}$  an



Fig.7 BER characteristics of the present scheme for signal generation and photodetection. The BPSK bit rate was 156 Mbps. The inset shows an I/Q diagram of the signal.

error-free operation in other words, was achieved at the received optical power of -17dBm. However, it was founcl that there exists an asymmetric feature in the I/Q diagram in Fig.7. This is probably due to imbalance in the V $\pi$ / voltages of two phase modulators.

## 4. Conclusion

A novel LN modulation technique for synthesizing a pair of dual-mode optical BPSK signals in an orthogonal phase relationship has been proposed for crosstalkfree generation of photodetected quadrature PSK signals at the receiver of a fiber optic mm-wave link. With a single LN modulator having dual RF inputs and carrier suppression together with the quadrature bias, i.e., a  $\pi/2$  phase offset between two optical paths, two BPSK signals have been generated and mergecl without causing nonlinearity-oriented problems at the photodetection stage. We pointed out that this modulation scheme is beneficial for QPSK signal generation because of a reduction of unnecessary bandwidth broadening caused by sophisticated transient trajectories in the previously, proposed method. The operation principle has been confirmed in preliminary experiments for 60-GHz-band signals both with an optical SSBM device and with a dual-electrode MZM device.

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